Roll to Roll (R2R) Processing Technology Assessment

1

2

4	Contents		
5		tion to the Technology/System	2
6	1.1. Intr	roduction to R2R Processing	2
7	1.2. R2F	R Processing Mechanisms	3
8	2. Technolo	ogy Assessment and Potential	7
9	2.1. Ber	nefits of R2R Manufacturing	7
10	2.2. R2F	R Processing Applications	7
11	2.3. Cha	allenges to R2R Manufacturing	11
12	2.4. Pub	plic and private activities to date	12
13	2.4.1.	Current Research Efforts by DoD	13
14	2.4.2.	Current Research Efforts by DOE	14
15	2.5. R&	D in R2R Processing	18
16	2.5.1.	Technological Needs of R2R Processing	18
17	2.6. Em	erging Processes and Tools for R2R	22
18	2.6.1.	Atomic Layer Deposition (ALD)	22
19	2.6.2.	Potentiometric Stripping Analysis for Electroplated Alloys	22
20	2.6.3.	High Temperature R2R Processes	22
21	2.6.4.	Standards Development	23
22	2.7. Key	<pre>rTechnology/Application Opportunity Areas</pre>	23
23	2.7.1.	Membranes	23
24	2.7.2.	Advanced Deposition Processes	23
25	2.7.3.	Flexible Electronics	23
26	2.7.4.	Battery Technology	25
27	2.7.5.	PEM Fuel Cells	25
28	2.7.6.	Photovoltaics	26
29	2.7.7.	Metrology and Quality Systems	27
30	2.4.1.1.	Embedded Thermal Energy	27
31	2.8. Tec	hnology Roadmaps Applicable to R2R Manufacturing	27

32	2.9. Workshops on R2R Processes and Manufacturing	28
33	3. Risk and Uncertainty, and other Considerations	28
34	3.1. Risks and Uncertainties of Using R2R Processes and Manufacturing	28
35	4. Sidebars: Case Studies	
36	4.1. Thin-Film Solar Cell Efficiency Record Set By First Solar (Again)	
37	4.2. Commercial Buildings Integration of Energy Saving Window Coatings	32
38	5. References	32

40

1. Introduction to the Technology/System

41 42 43

1.1. Introduction to R2R Processing

44 Roll-to-roll (R2R) is a family of manufacturing techniques involving continuous processing of a flexible 45 substrate as it is transferred between two moving rolls of material [1]. R2R is an important class of 46 substrate-based manufacturing processes in which additive and subtractive processes can be used to 47 build structures in a continuous manner. Other methods include sheet to sheet, sheets on shuttle, and 48 roll to sheet; much of the technology potential described in this R2R Technology Assessment conveys to 49 these associated, substrate-based manufacturing methods [2]. R2R is a "process" comprising many 50 technologies that, when combined, can produce rolls of finished material in an efficient and cost 51 effective manner with the benefits of high production rates and in mass quantities. High throughput and 52 low cost are the factors that differentiate R2R manufacturing from conventional manufacturing which is 53 slower and higher cost due to the multiple steps involved, for instance, in batch processing. Initial capital 54 costs can be high to set up such a system; however, these costs can often be recovered through 55 economy of scale. Figure 1 illustrates an example of R2R processing of a state-of-the-art nanomaterial 56 used in flexible touchscreen displays. [3] 57

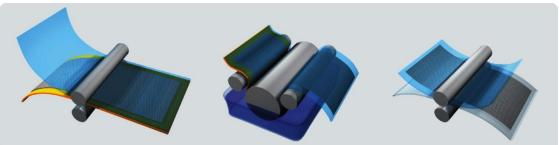


Figure 1 – R2R processing of graphene film for flexible touchscreen displays [3].

- 59 Today, R2R processing is applied in numerous manufacturing fields such as flexible and large-area
- 60 electronics devices, flexible solar panels, printed/flexible thin-film batteries, fibers and textiles, metal
- foil and sheet manufacturing, medical products, energy products in buildings, and membranes to name
- a few. In the field of electronic devices, R2R processing is a method of producing flexible and large-area
- electronic devices on a roll of plastic or metal foil. Substrate materials used in R2R printing are typically
- 64 paper, plastic films or metal foils. Stainless steel is sometimes used because it is durable and has a high
- 65 temperature tolerance [4]. The global flexible electronics (flexible display, flexible battery, flexible

- 66 sensor, flexible memory and thin film photovoltaic (PV)) market revenue was estimated to grow from
- 67 \$3.4 billion in 2013 to \$13.23 billion in 2020 at a compound annual growth rate (CAGR) of 21.73% from
- 68 2014 to 2020. The consumer electronics market is expected to grow at a CAGR of 44.30% and is
- 69 supported by advancements in flexible displays, flexible sensors and thin-film solid-state batteries that
- can be produced using R2R processes. [1] [5]
- 71
- 72 Further development of R2R production capabilities that are energy efficient, low environmental impact
- and lower cost and that are employed to manufacture technologies and products for clean energy
- applications will have a "global impact" in the manufacturing industry. There are huge savings in energy
- just from higher throughputs since the tools and equipment used in R2R manufacturing (per unit area of
- 76 manufactured roll) are using less energy for a much shorter period of time relative to conventional
- manufacturing processes. Additionally, efficiencies are obtained from more efficient deposition
 processes, for example, that would provide additional savings in energy. Breakthroughs that will have
- 79 high impact, and therefore high value, are in the nano-manufacturing community. [1]
- 80
- 81 The R2R Tech Assessment reviews current state-of-the-art technologies, clean energy applications, and
- 82 industry investments to categorize advances in R2R manufacturing in the areas of metrology,
- 83 equipment, carriers/webs, substrate materials, process improvement, alternative applications and other
- 84 possible innovations. These efforts will serve to enable and maintain the competitive nature of R2R
- 85 manufacturing for the domestic U.S. industry.86

87 **1.2. R2R Processing Mechanisms**

Silicon wafers, cadmium-telluride solar cells, battery electrodes, fuel cell membranes, and high performance window films are just a few examples of materials that have clean energy applications and are characterized by a two-dimensional functional surface, often with one or more coated or deposited layers. Not surprisingly, these materials are often made using similar processes—namely continuous rollto-roll, belt-fed, or conveyor-based processes that enable successive steps to build a final construction at high throughput.

94

As a comparison of the variety of processes that can be used for R2R manufacturing, a brief descriptionof each are provided here.

97

98 • **Deposition** – Evaporation, sputtering, and chemical vapor deposition (CVD) can all be easily 99 implemented in R2R processing. Multilayer sputtering systems are the most common. The entire 100 roll is loaded into a vacuum system where it is relatively easy to sputter or evaporate different 101 materials onto a substrate without crosstalk as shown in Figure 2. This is more difficult in CVD 102 where reactive gas barriers are needed within the vacuum system. [7] When the substrate 103 moves past the sputtering source, the deposition rate of material varies. The processing rate 104 influences the thickness and sequence of layers in a multilayer coating which also depends on 105 rotation speed, initial position and orientation of the substrate. CVD can be used to deposit 106 materials on a continuous roll of flexible metal foils, plastics, and other materials in place of 107 individual substrates. This technology has been used for superconductor tape production and 108 nanomaterial synthesis and is growing in popularity for thin film solar deposition. 109

113

118

119 120

121 122

123 124 125

126

127

128

129 130

131

132 133

134

135

136

137

138 139 140

141 142

143

144

145

146

147

148

149

150

151 152

153

154

155 156

157

the

rollers

in the

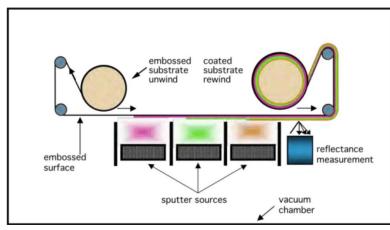
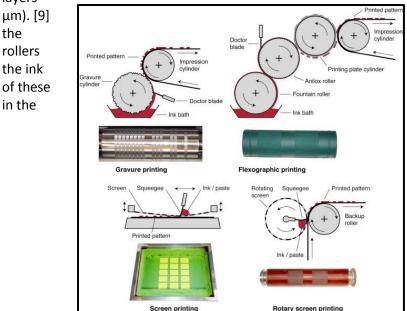


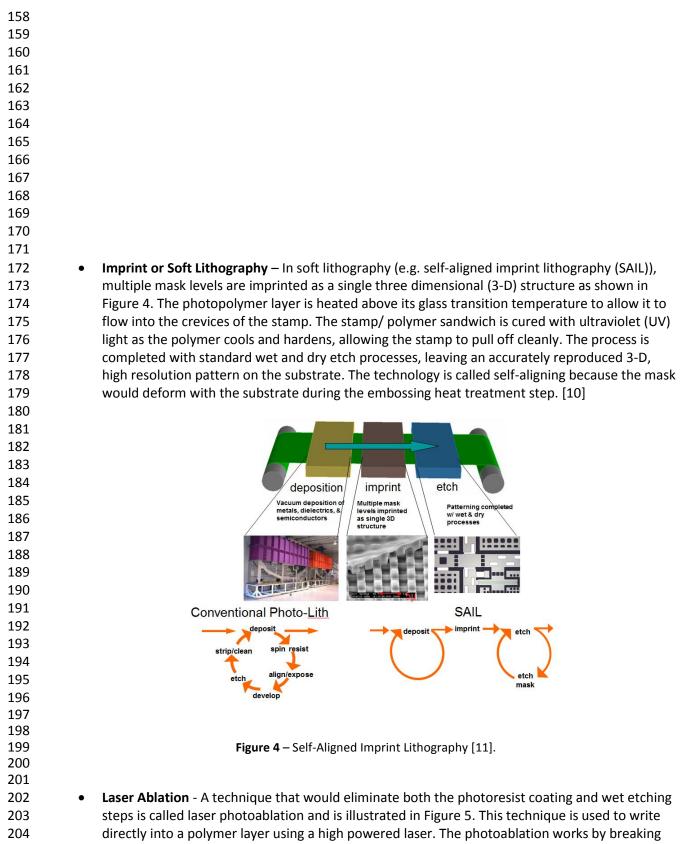
Figure 2 – Inline vacuum coater and sputtering process [1].

- Gravure A type of printing process which involves engraving the image onto an image carrier. In gravure printing, the image is engraved onto a cylinder because, like offset printing and flexography, it uses a rotary printing press. The entire patterned cylinder is covered with ink as shown in the upper left corner of Figure 3. The excess ink is doctored off, leaving ink in the cupshaped engraved pattern. The plate cylinder is brought into contact with the impression cylinder to transfer the ink to the substrate. [8] Once a staple of newspaper photo features, the process is still used for commercial printing of magazines, postcards, and product packaging.
- Flexographic Printing - A form of printing process which utilizes a flexible relief plate as shown in the upper right corner of Figure 3. It is essentially a modern version of letterpress which can be used for printing on almost any type of substrate, including plastic, metallic films, cellophane, and paper. It is widely used for printing on the non-porous substrates required for various types of food packaging. Only the raised area in the pattern cylinder is inked and the pattern is transferred to the substrate. [8]
- Flatbed and Rotary Screen Printing In flatbed printing, a squeegee, moves relative to a mesh, • then forces the ink through the open area and onto the substrate. The wet layer thickness is defined by the thickness as well as the open area of the mesh and generally relative thick wet layers



can be achieved (10–500 In rotary screen printing, substrate moves through past the squeegee forcing onto the substrate. Both processes are illustrated lower half of Figure 3.

Figure 3 - R2R Processing diagrams for organic electronics/thin films [6].



molecular bonds in polymer layer, fracturing the polymer into shorter units that are "kinetically

206 207 208 209 210 211 212	ejected" upon removal. The amount of material ejected can be tuned by adjusting the wavelength, energy density and pulse width of the xenon-flouride (XeF) excimer laser (a form of UV laser which is commonly used in the production of microelectronic devices) used for ablation and is capable of reproducing ablation	Irradiation
213 214 215 216 217	depth to within 0.1 μm across large areas of the substrate. Examples of ablatable polymers are polyimides (e.g "Kapton [®] ") and polyethylene terephthalate (PET) (e.g Mylar [®]), which are also commonly used substrates in flexible electronics	Absorbtion
218 219 220 221	 Offset Printing - A commonly used technique in 	Bond-Breaking
222 223 224 225 226	which the inked image is transferred (or "offset") from a blanket cylinder that bridges the plate cylinder and the substrate. The pattern is transferred to the blanket (usually made of rubber), and then transferred to the substrate	Ablation Figure 5 – Schematic of the laser ablation process [10].
227 228	 [8]. Inkjet Printing - While laser ablation may be called a balancidered on additive technique. Bother then we have a seried on a dditive technique. 	

- Inkjet Printing While laser ablation may be called a subtractive technique, inkjet printing can
 be considered an additive technique. Rather than your home, graphics-oriented inkjet printer,
 an array of piezoelectric print heads are required for the deposition of conducting organic
 solutions at precise locations [10].
- 232
- Table 1 provides a comparison between some of these different printing methods in terms of their
 theoretical capacity and practical applicability for large-scale R2R production.

- 237 238
- Table 1 Comparison between different printing methods in terms of their theoretical capacity and practical

 applicability for large-scale R2R production

Printing Method	Speed	Wet Thickness (μm)	Resolution (μm)	Start/Stop	Complexity	Applicability
Flatbed Screen Printing [5]	Low	5-100	100	Yes	Low	Limited
Rotary Screen Printing [5]	High	3-500	100	Yes(a)	Medium	Very good
Inkjet Printing [5]	Medium	1-5	<50	Yes	High	Limited, materials must be jettable
Flexography [5]	Very high	1-10	<50	Yes(a)	Medium	Very good

DRAFT - PRE-DECISIONAL - DRAFT

Imprint or soft lithography [20]	High (>5 meters/min)	0.1 (100 nm demonstrated)	New technology
Laser ablation [20]	Low	~10	Thermal effect sensitivity
Gravure [12]	High	>0.07 (70 nm demonstrated)	Very Good

239

(a) - Stopping should be avoided. Risk of registration lost and drying of ink in anilox cylinder. Short run-in length

240

241 Substrates that are used in R2R processing may be made of a variety of materials depending on the

242 application and processing steps involved in fabrication. Plastic films are desirable for their

transparency, flexibility and toughness, but are often susceptible to degradation and dimensional

distortion at high temperature [10]. Where transparency is not required, stainless steel foils may be

chosen as they tolerate higher temperatures than plastics. Other materials, such as aluminum andcopper alloys, may also be used.

247

248 Circuit patterns may be formed on the flexible substrate in a variety of ways. Some such production lines

employ inkjet technology to deposit material onto the substrate. This process is similar to how an inkjet

printer deposits ink onto paper. Some facilities employ photolithography, using light to etch away a

pattern on the substrate that may then be filled with another material. Other techniques using
 ultraviolet light, lasers, and so on, may also be used to imprint the substrate with electrical circuitry.

253

A variety of other manufacturing steps may also be accomplished using R2R processing. In addition to laying down circuit patterns, such steps as die cutting, laminating, placing labels, cleaning, and more may be performed. Heat sealing and application of a variety of coatings may also be included in a roll-toroll processing operation.

258

2. Technology Assessment and Potential

259 260

261 2.1. Benefits of R2R Manufacturing

Benefits of R2R processing include high production rates and yields. This technique can help reduce the
cost of manufacturing through economy of scale as it allows devices to be fabricated automatically in
mass quantities. Although initial capital costs can be high to set up such a system, these costs can often
be recovered through the economic advantages during production [13]. For conventional sheet-fed
systems, sheet handling and off-line drying consume a good portion of the overall cycle time.
Continuous production can be achieved on a roll-to-roll system due to in-line hot air drying and
sophisticated web-tension controls.

270

271 2.2. R2R Processing Applications

272

273 The R2R technology has evolved to support a wide range of industrial applications used for both

traditional and "cutting-edge" products [1]. Two flexible thin film products made by R2R processing areshown in Figure 6.



DRAFT - PRE-DECISIONAL - DRAFT

- similar in concept and allow long sheets of material such as glass to be processed while moving and
- 324 supported on a liquid surface. Finally, conveyors are used for cases such as silicon photovoltaic wafers
- 325 wherein discrete parts are processed in a continuous fashion, although much processing is accomplished
- 326 using batch process methods.
- 327
- 328



- 329
 - 330 331

Figure 7 - (Left) screen printing and (right) tape casting. Photos from M. Richards, Versa Power Systems

- 332 333 Many different permutations of processes are used on these continuous lines—too many to review in 334 detail. Instead, broad categories of processes are highlighted below. A high level discussion on various 335 printing/coating/deposition mechanisms was already covered in section 1.2. Most of the materials of 336 interest involve some kind of coating or deposition—often several in series—to create functional layers 337 and surfaces [7]. These additive processes are categorized by the pressure at which the coating is 338 applied: either at atmospheric (room) pressure or in a vacuum. Atmospheric coatings take several 339 generic forms. Roll coating is characterized by two or more rollers, in a wide variety of configurations, 340 being used to "pick up" a thin layer of liquid from a bath and apply it to a surface of a web. Knife coating is similar to roll coating, wherein a stationary bar or rod—the "knife"—, commonly known as a "Dr. 341
- Blade" is set to a certain stand-off distance from the web and is used to control the amount of liquid
- deposited onto the web from a reservoir in process referred to as tape casting [14]. Figure 8 illustratesthis process.
- 345



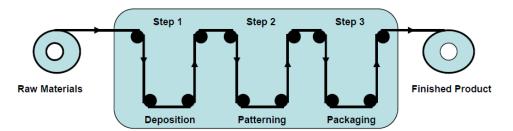
- Figure 8 Traditional, current technology "Laboratory-Scale" Tape Caster and "Dr. Blade", manufactured by HED
 used to deposit thick-film slurry on moving web "substrate.
- 349

350 Various masks or other limits to the location or position of the coated liquid can be employed, as in 351 screen printing. A wide variety of techniques are generically referred to as die coating, characterized by 352 a sheet of coating being dropped or laid onto the web. The die comprises two or more typically metal 353 plates with machined flow-fields between to enable the creation of a highly uniform sheet of coating. 354 And finally, for the atmospheric coatings, spray methods are often employed using one or an array of 355 spray heads to coat the web from side to side. Low temperature systems are used most often, including 356 a variety of jet methods as well as systems where the head is ultrasonically actuated to break up 357 droplets and particles into a very fine spray. In cases where the substrate or base material can withstand 358 the thermal load, high temperature sprays can be used, including electrical arc and plasma-based 359 methods. In almost all cases of liquid coatings applied under atmospheric pressure, some kind of drying 360 and/or curing of the coating is required. Drying is used to drive off solvents that are used to make a 361 coatable mixture but are not desired in the final layer and is typically accomplished using heated gas or 362 infrared heat sources. Curing is a post-treatment process to finalize the chemical or morphological 363 nature of the coating by irradiation with an energy source such as infrared or ultraviolet lamps, or an 364 electron beam. 365

Vacuum coating techniques incorporate a number of vapor deposition technologies, such as sputtering and evaporative coating. These processes are typically used for very thin coatings—usually less than a micrometer in thickness, referred to thin-film processes [15]. Importantly, when vacuum processes are used in continuous production, complicated and expensive line equipment must be employed to allow movement of the web while still maintaining very low pressure. Several mechanical processing steps are also used including cutting or sawing processes, texturing of the surface, and creation of electrical junctions. Figure 9 shows a reel-to-reel vacuum deposition process.



373	
374	Figure 9 - Reel-to-reel vacuum deposition line.
375	Photo from Global Solar Energy, NREL 13414
376	
377	Many of the described processes have been available to the manufacturer for many, i.e. > 40 years.
378	An idealized R2R manufacturing process with the essential steps from the raw materials to the
379	finished product is illustrated in Figure 10. However, because of demand for increased process
380	competitiveness, new applications and equipment, researchers have continued to evolve the wide
381	range of processes to meet innovation challenges. Whereas in the 1970s one was barely able to
382	print 25 μ m wide lines and traces on a 250 μ m thick substrate, today, it has been demonstrated that
383	investigators can routinely printi sub-200 nm features in a continuous web [16].



386

Figure 10 - Idealized Roll-to-Roll manufacturing process flow [4]

387 Regardless of the process, each technology where 2-D processing is used exhibits a wide range of net process yields. In both the thick-film and thin-film microelectronics industries substrate surface 388 389 imperfections, chemical impurities inconsistencies in substrate thickness, flatness and planarity can 390 all result in considerable yield loss. These losses do not include additional issues due to improper 391 deposition of conductors, devices, vias (small opening for an electrical connection) and other 392 through-holes, mask alignments, etch issues, oxidation, etc. Nor do these losses include "pre-393 fabrication" yield losses during ingot preparation, doping, thermal processing, wafering, dicing and 394 other more mechanical issues as simple as "breakage". Overall "net-yields" for thick-film transducer 395 and thermistor products were as low as 25 to 30 percent, while those encountered for select discrete thin-film fabricated products ranged to lows of 40 to 60 percent. Indeed 2 dimensional R2R 396 397 processing is one which provides a manufacturer with a means to rapidly increase capacity and 398 productivity. However, the specific process in-use and all tools, materials, designs, etc., must be 399 reliable, reproducible and be capable of consistently yielding product to the prerequisite 400 specifications. The "openness" of government and industry to form partnerships will solve 401 challenges with substrate materials, morphology, and hardware/software that are common in all 402 applications. [4]

403

404 2.3. Challenges to R2R Manufacturing

The following summarizes some of the challenges faced by industry when considering R2Rmanufacturing to produce a technology.

- In order to succeed as a viable manufacturing alternative, R2R processing technologies need to
 show a dramatic reduction in cost compared to the traditional technologies [10].
- 409 In most cases, the low cost of R2R manufacturing can only be exploited if the facility is operating • close to the full production capacity. In R2R processing the challenge is in the limited variety of 410 411 products that can be run, and the large capacity of any one facility. The variety of products is limited because the sequence of process steps is fixed. This is in contrast to a typical 412 413 semiconductor fabrication, where the individual pieces of automated equipment stand alone 414 and multiple process sequences are supported. The advantage of multiple process sequences is that a much larger number of products can be manufactured in the facility helping to keep it 415 416 fully utilized. [7]
- The other challenge is that the low cost of R2R results from the rapid process time, that means that even more production is needed to fully utilize the facility. Therefore an application must have very high volumes and /or large areas to utilize a R2R fabrication supporting a single process sequence. Solar cells and display films are two applications where the devices are large area and the potential markets are also very large [7].

- The infrastructure for manufacturing large area flexible displays does not yet exist, so factories
 wishing to incorporate R2R processing technologies would have to deal with very high start-up
 costs due to custom-built tools [10] [17].
- 425 As R2R manufacturing processes transcend from fundamental science to laboratory-scale 426 production platforms within academia and industry, the transition to pilot-scale production is 427 hampered by several factors that can benefit from standards. The resulting delay in the 428 commercialization cycle includes losses resulting from incoming materials variations, process 429 technologies, process tolerances, equipment and operator inconsistencies, and lot-to-lot 430 variations, making it extremely costly and difficult to scale to R2R production capacity. 431 Standards are necessary to assist in the translation of discrete processes to an integrated 432 manufacturing flow [1].
- 433

434 2.4. Public and private activities to date435

The "additionality" for R2R manufacturing resides in many entities. Government agencies (DOD Army,
NSF, DOE Offices), national labs (LBNL, ORNL, NREL, PNNL, etc.) large companies (PlasticLogic, POLYIC,
Philips), and academia (University of Mass Amherst, University of Kentucky, Binghamton University)

438 Philips), and academia (oniversity of Mass Annerst, Oniversity of Kentucky, Binghamton Oniversity)
 439 have current interests in energy saving technologies that can be produced by R2R manufacturing

- 440 processes.
- 441

A 2013 report by Information Handling Services (IHS) stated that "of 483 roll-to-roll processing
technology patents, 23 flexible OLED-related U.S. published/issued patents and 9 international patents
were extracted as key patents. Looking at the application trend of 483 patents (Figure 11) on roll-to-roll
processing technology, the number of applications has continuously increased since mid-2000s, and
many were applied in the U.S. Major applicants include 3M Innovative Properties, SiPix Imaging, Fuji
Film, and General Electric. Amid vigorous developments of roll-to-roll processing technologies,
competition among companies in the U.S., Japan, and South Korea gets increasingly fierce." [18]

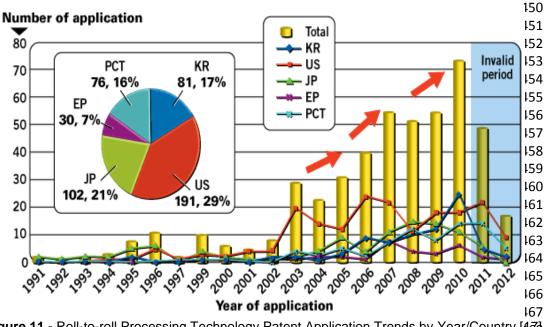


Figure 11 - Roll-to-roll Processing Technology Patent Application Trends by Year/Country [47] 469

- Although R2R processes have been used in various applications for decades, very few patents have been
 filed until the early 2000's, as can be seen in Figure 11, and is steadily increasing over the last decade.
- 473 474

2.4.1. Current Research Efforts by DoD

The combined services, including the Air Force Research Laboratory (AFRL), t the Army Research
 Laboratory (ARL) and the Naval Research Laboratory (NRL), have all been actively cooperating in

- 477 research on micro-electronics, focused on flat panel displays [19].
- 478
- 479 More recently, ARL has sponsored research in thin film transistor arrays for displays and digital • 480 x-ray detectors. Currently, ARL manages The Flexible Display Center (FDC), based out of Arizona 481 State University. The FDC is a unique public-private partnership with the goal to accelerate the 482 availability of the flexible display technology for the Soldier (FY04-FY13). Some of the results of the FDC work, include demonstration of the world's first flexible electrophoretic display (E-ink 483 484 Corporation) using the ASU patented bond-debond manufacturing process, development of the 485 ultra-large format flexible full color OLED displays (14.7" diagonal) and x-ray detector arrays (FDC-Defense Threat Reduction Agency (DTRA) and the Palo Alto Research Center (PARC))), a 486 487 range of hand-held devices with an integrated flexible reflective displays (E-ink Corporation), 488 flexible reflective displays used in an Army field experimentations (Physical Optics Corporation) and the fully flexible tablet for Soldier experimentations (Physical Optics Corporation), flexible 489 490 microelectromechanical systems (MEMS), among others [20]. Figure 12 illustrates an R2R processed Silicon Radio Frequency Identification (RFID) chips. [21] 491
- 492



- 493
 494 Figure 12 Silicon Radio Frequency Identification (RFID) chip with antenna processed using R2R technology [20].
- 495 496 497

• Further, starting in FY11, DTRA and ARL are collaborating on developing flexible digital x-ray detectors using the display manufacturing process, although currently the manufacturing

- 497 detectors using the display manufacturing process, attrough currenti 498 process is plate to plate lithography, R2R is under consideration.
- A project with Hewlett-Packard (HP) and PowerFilms which was designed to advance plate to plate and R2R, Self-Aligned Imprint Lithography (SAIL) process for display applications based on amorphous silicon (Si) thin film transistor (TFT) arrays. Although the program was concluded without any commercialization of technology in FY11, process feasibility was demonstrated.
 Effort is now continuing via an ARL and FlexTech alliance focused on SAIL development.
- The ARL has investments through the FlexTech Alliance, a 30 industrial member consortium of both domestic and international organizations. Their focus includes work on zinc-polymer battery chemistries (referred to as Imprint Energy) that can be processed using screen printing fabrication approaches. Using some of the more mature zinc-polymer chemistries, battery process development has advanced enough to demonstrate prototypes which provide

509reasonable performance. The effort also included TFTs and R2R processed OLEDs among others.510The FlexTech Alliance also sponsored flexible Si complementary metal-oxide-semiconductor511(CMOS) chips on paper, soldier health monitoring systems and other electronics designed to512provide and enable prognostics and diagnostics. Many of these exploratory programs are at a513Technology Readiness Level (TRL) 1-3. The paper-based flexible Si project is further advanced at514a TRL 6 and Manufacturing Readiness Level (MRL) 3-4. This project represents a non-traditional515flexible Electronic Manufacturing Services (EMS) program.

516 517

2.4.2. Current Research Efforts by DOE

518 The DOE supports research and development (R&D) in the area of fuel cells, energy efficient buildings, 519 solar energy, batteries and electric vehicles, advanced manufacturing technologies and fossil fuel energy 520 as part of a broad portfolio of activities to secure the nation's energy future.

521

534

542

522 The Fuel Cell Technology Office (FCTO) develops fuel cells, which use fuels from diverse • 523 domestic resources to generate electricity efficiently, and hydrogen, a zero-carbon fuel when 524 produced from renewable resources. These technologies comprise key elements of the DOE 525 portfolio. Fuel cells address energy security by reducing or eliminating oil consumption in 526 transportation energy generation applications. Fuel cell electric vehicles (FCEVs) operating on 527 hydrogen from distributed natural gas can almost completely eliminate petroleum use. At 25% 528 market penetration by 2050, FCEVs can reduce consumption of petroleum by more than 420 529 thousand barrels per year (Mbbl/yr) compared to 435 Mbbl/yr consumed by the same number 530 of internal combustion engine vehicles (ICEVs). Fuel cells can also provide highly reliable grid support; for example, during Hurricane Sandy, 22 of the 23 400-kilowatt (kW) United 531 532 Technologies Corporation (UTC) Power (now ClearEdge Power) stationary fuel cells in New 533 England and New York provided continuous power to buildings.

535Assuming 15,000,000 fuel cell vehicles are manufactured per year (10% of the world market in5362030), 4.5 billion membrane electrode assemblies per year produced at a rate of 11,700537membrane electrode assemblies (MEA)/minute are needed for the fuel cell stacks. To achieve a538quality requirement for MEAs of 0.1% stack failure, only one critical MEA failure in 300,000539would be allowed; and for six sigma stack quality, only one critical MEA failure in ~90 million540would be allowed. Quality control (QC) is critical and tools are needed. However, efforts like541these exemplify an "enduring economic benefit" for both the public and commercial sectors.

543 As an example of R2R manufacturing challenges, Ballard Material Products (now AvCarb) was 544 funded to develop a continuous mixing and coating process to manufacture gas diffusion layers 545 for polymer electrolyte membrane fuel cells. Enhancements to the coating line included 546 modified solutions (e.g. increase solids to reduce wet-load) and optimized dryer profile utilizing 547 dew point sensors to prevent premature drying of the top layer. Using modified slot heights and 548 a multilayer coating head, defect-free coatings and improved cross-web-basis weight uniformity 549 resulted in successfully-produced defect-free anode and cathode materials. Improved 550 repeatability of basis weights was achieved by installing Micro Motion flow meters for each 551 solution. Issues still to address include formation of small agglomerates in the in-line ink due to solution modifications, trade-offs between modified solutions and mix quality, high amount of 552 553 entrained air present with in-line ink, and examination of methods to improve a de-gas 554 technique to remove air more efficiently, Bottom line is that gas diffusion layer (GDL) costs have 555 been reduced over 50% since the start of the project and Manufacturing capacity has been 556 increased nearly four-fold since the project began.

558 There is a **"proper role of government"** in transitioning technology to the commercial sector. 559 One example was through the DOE Market Transformation Appropriations and the American 560 Recovery and Reinvestment Act (ARRA). DOE successfully deployed nearly 700 fuel cell material handling units with such customers as FedEx, Sysco, and Whole Foods. These deployments led 561 562 to almost 5,400 industry funded and "on order" units with no DOE funding. The ARRA 563 investment for these fuel cell powered lift trucks is about \$9.7M with an industry cost share of \$11.8M. ARRA support was used to demonstrate the commercial competitiveness of fuel cell 564 565 backup power for telecommunications with over 820 fuel cell units and more than 80 units from Market Transformation Appropriations. As a result of government funding, sales of these 566 567 technologies continue to grow without federal support with almost 3,600 industry-funded and 568 "on order" fuel cell units for backup power.

557

569

579 580

581

582 583

584

585

586 587

570 Solar Energy Technologies Office (SETO) (through the SunShot Initiative) invested \$30 million • (with 50% cost share matching) in establishing a consortium called the U.S. Photovoltic 571 572 Manufacturing Consortium (PVMC) in Albany, New York to support copper-indium-galliumselenide (CIGS) photovoltaic (PV) products. Initially, a Manufacturing Demonstration Facility 573 574 (MDF) was established for manufacture of CIGS on a steel web. US-based companies (Global 575 Solar, MiaSole, NuvoSun and Ascent Solar) were interested; however, the dramatic price 576 decrease of conventional crystalline silicon photovoltaics has led to several other U.S.-based R2R 577 CIGS start-ups going out of business over the last two years. There has also been Asian 578 acquisition of all the companies still in business in the United States (except NuvoSun).

U.S. companies, still working in the CIGS R2R area, are not prepared to use the PVMC MDF and share what they consider to be proprietary processes in the context of a consortium. This is an example where "openness" was not a contributing factor. Public announcements indicate that these companies intend to scale in Asia and other developing nations. As a result, SETO has redirected the consortium to work on "downstream" issues in support of flexible CIGS, such as establishing the methods for installation of flexible PV modules and determining the reliability of flexible PV.

- 588 The Building Technologies Office (BTO) has a number of existing Investments in R2R • 589 manufacturing including architectural applications research with Lawrence Berkley National 590 Laboratory (LBNL) regarding airflow panel membranes, with Oak Ridge National Laboratory (ORNL) in R2R sensors for building applications, with the National Renewable Energy Laboratory 591 592 (NREL) investigating VI window film, with ITN Energy Systems and the Electric Power research Institute (EPRI) work on Low-energy/Electrochromic window film, with 3M/LBNL investigating 593 594 daylighting film for windows, with 3M/ORNL (within the China Clean Energy Research Center (CERC) program) work focused on primer-less, self-adhered air sealing membranes, with 595 596 PPG/Pacific Northwest National Laboratory (PNNL) developing infrared (IR) responsive window 597 coatings, and with Heliotrope Technologies work on near IR Electrochromic (NIR EC) window 598 coatings. 599
- 600The Advanced Manufacturing Office (AMO) (through prior programs supporting Inventions and601Innovation as well as Industrial Sensors and Small Business Innovation Research (SBIR)) invested602approximately \$1 million in cadmium-tellurium (CdTe) solar cell development and603manufacturing; approximately \$1 million in advanced solar-reactive glazing, coating and604manufacturing technologies to reduce unwanted solar gain through windows, skylights and

605automotive windows; approximately \$1 million among battery technologies, super-capacitor606technologies, superconducting cable technologies; and approximately \$2M in advanced sensor607technologies. AMO investments focused on lithium-ion (Li-Ion) battery technology incorporating608R2R processing in the effort. A MDF has been established at ORNL with focus on electrolyte609materials used in laminated planar battery pack assemblies.

611 **The Office of Fossil Energy (FE)** has investments concerning CO₂ membranes. Those involving • R2R manufacturing processes are being considered or used to manufacture several different 612 613 polymeric and ceramic/metallic membranes for CO₂ separation for power plants. Similar 614 processes are used to manufacture existing commercial water filtration and natural gas 615 processing membranes. FE has not been investing in the commercial production of membranes, 616 but rather left the commercialization of the materials to the project performers and their 617 partners. Issues such as defect control during coating and drying, substrate and active layer bonding, and quality control/quality assurance (QC/QA) are consistent issues with 618 manufacturing CO₂ membranes. Many of the technologies are at the pilot scale and much of the 619 620 manufacturing processes efforts are considered at a similar scale of development (TRL 4-5). The 621 investments in membranes detailed in Table 2 for post-market and pre-market applications have 622 been made to date and may benefit from a concerted effort to improve the R2R manufacturing 623 processes. 624

625 626

610

627

Application	Company/Agency	Substrate	Active Layer	Туре
Post	Ohio State University	Polymer - Polyethersulfone	Zeolites	Spiral Wound
Post	Membrane Technology & Research, Inc	Polymer	Polymer	Spiral Wound
Post	General Electric	Polymer	Phosphazene	Hollow Fiber
Post	Gas Technology Institute	Poly ether ether ketone (PEEK)	Perfluoro-oligimer	Hollow Fiber - Gas/Liquid
Post	Argonne National Laboratory	Alumina-Zirconia	Pd/TZ-3Y cermet	Long-tubes
Post	Pacific Northwest National Laboratory	Ceramic/Metallic	Ionic Liquid	Sheet/Plate
Pre	Praxair	Ceramic	Pd alloy	Shell and Tube
Pre	Eltron	Metal Alloy	Not Applicable	Shell and Tube
Pre	Worcester Polytechnic Institute	PSS-316L	Pd Alloy	Shell and Tube
Pre	Pall Corporation	Ziconia Coated SS Tubes	Pd Alloy	Shell and Tube
Pre	Los Alamos National Laboratory	Polybenzimidazole (PBI) - Polymer	PBI Polymer	Hollow Fiber

 Table 2 - Office of Fossil Energy Investments in CO2 Membranes

628 629

630

631

National Renewable Energy Laboratory (NREL)

NREL efforts developed a defect diagnostic in house by applying a direct current (DC) potential to a membrane electrode assembly and then monitoring the heat generated in the MEA using

an IR (heat) detector. Areas in which there is a defect generate no heat and no signal for the
detector. NREL demonstrated the IR/DC technique on Ion Power's production coating line for
detection of electrode (on decal) defects.

R&D at NREL is addressing quality control needs for scale-up of fuel cells and cell component
manufacturing on weblines. The approach includes understanding quality control needs from
industry partners and forums, developing diagnostics, using modeling to guide development,
using in situ testing to understand the effects of defects, validating diagnostics in-line, and
transferring technology to industry.

641 642

643

644

645

646 647

648

649

650 651

652

653

654 655

656

657 658

659

660

661

662

663

664 665

635

• National Science Foundation (NSF)

NSF supports fundamental and translational research efforts within the Center for Hierarchical Manufacturing, an NSF-supported Nanoscale Science and Engineering Center (NSEC), leveraging \$4 million/year of federally-funded nanomanufacturing research, The research program focuses on the integration of nanofabrication processes for 30 nanometer and smaller elements based on directed self-assembly, additive-driven assembly, nanoimprint lithography, high fidelity 3-D polymer template replication, and conformal deposition at the nanoscale with Si wafer technologies or high-rate R2R-based production tools.

NSF also supports fundamental and translational research efforts within the Nanomanufacturing Systems for Mobile Computing and Mobile Energy Technologies (NASCENT), an NSF-supported Engineering Research Center (ERC) leveraging \$4 million/year of federally-funded research on innovative nanomanufacturing, nanosculpting and nanometrology systems that could lead to versatile methods for the high-volume nanomanufacturing of mobile computing devices such as wearable sensors, foldable laptops and flexible batteries.

Other

Over the last 10 years, the European Union has had significant investments in R2R manufacturing and related printing plate-to-plate using organic based TFTs for displays and RFIDs. Some organizations involved, include: PlasticLogic (focused on plate-to-plate), POLYIC (involved in R2R RFID), and Philips and one of its subsidiaries, PolymerVision. The former company has recently introduced a range of flexible electronic OLED displays designed as "wearable" devices.

666 Commercial alkaline battery manufactures focus on processes using R2R process techniques.
 667 Goal is to "build" structure, which includes "can" material, anodes and cathodes in a continuous
 668 process, with individual assembly achieved via a mechanical formatting operation at the end of
 669 the R2R process.

- The University of Massachusetts (UMass Amherst) within the Center for Hierarchical
 Manufacturing sponsors the "Research Cluster R: Roll to Roll Process Research Facility. The
 facility supports efforts focused on nano-imprint lithography (NIL) process and development.
 Current investment allows work up to 6-0inch wide format using a range of R2R equipment and
 analytical tools. Focus areas include; planarization, imprint embossing and patterning,
 alternative materials and membranes, functional hybrids, viscoelastic fluids, R2R integration and
 design for manufacturability.
- 678

The University of Kentucky Center for Applied Energy Research has a significant effort underway
which focuses on a range of energy applications, some of which involve R2R. Areas of interest
include low-cost carbon anode precursors, VRF, Thermoelectrics, etc.

Flexible "heater" circuitry for displays has been commercially available from companies such as
 All Flex Flexible Circuits, LLC for over 25 years. These products are fabricated using a mixture of
 R2R and batch "plate to plate" techniques, involving micro-electronics lithography printing and
 chemical etching processes.

The Center for Advanced Microelectronics Manufacturing (CAMM), a partnership between
Binghamton University (BU), Endicott Interconnect Technologies (EI), Cornell University and the
Flex Tech Alliance, is a prototype R&D facility in large area flexible electronics. The CAMM is part
of BU's New York State Center of Excellence in Small Scale Systems Integration and Packaging
(S3IP), which serves as an international resource for systems integration and packaging R&D.

- 2.5. R&D in R2R Processing

2.5.1. Technological Needs of R2R Processing

- **Providing a connection between emerging R2R process R&D and scaled manufacturing**: In order to extend R2R manufacturing technologies to volume manufacturing, several infrastructural needs must be established relevant to emerging processes and tools [1].
 - R2R manufacturing traditionally consists of coating and printing processes. While there are many companies engaged in R2R manufacturing, there remains a general lack of standardized infrastructure in some cases, and most academic institutions do not have R2R fabrication facilities. As a result, R&D data are still lacking on what are achievable with R2R processes and what are the limitations, especially in the context of throughput [1].
- Parameters affecting throughput and defects control for various processes need to be established. In addition, the necessary supply chain is lacking, and needs to be broadly established, along with standards. Standards developments cannot be underestimated, and a more concerted effort in this area is necessary. One way to address these issues may be through the establishment of pilot line facilities for development, demonstration and optimization of full processes. This infrastructure component would provide a vital step between lab coupon-scale development and production line scale-up, ultimately reducing risk and cost, and providing a more rapid development path for product commercialization. This is due to the high cost of roll-to-roll instruments. This can be alleviated by creating shared facilities (such as the Research Cluster R for Roll-to-Roll Processing at UMass Amherst) that will be accessible for academics and for industrial participants to try out some ideas, as well as establish emerging processes and materials for broader use [1].
- Previous DOE sponsored workshops [22] have identified a need to address equipment
 and quality issues. Equipment needs to support formats sufficient to meet nano-scale
 atomic layer deposition (ALD) and small-scale (e.g. microelectronics thin and thick-film)

726	to medium-scale (windows and window films) to large-scale (membranes for biofuel and
727	natural gas processing) fabrication.
728	Investigations for manufacturing development should focus on tools to feed pre-
729	requisite solutions, slurries at sufficient rates while controlling rheologies of these
730	materials, webs (tensile strengths, surface finish and release, materials, zero defect,
731	etc.), motor controls, motors (web speed control, tensioning, material "take-up", post
732	formatting, etc.), metrological instrumentation, simulation and design tools, control(s)
733	feedback and adjust, materials drying accessories, ventilation and effluent treatments,
734	incorporation of concurrent/simultaneous process using additive and subtractive, in-air,
735	other atmosphere and vacuum processing, precision alignment, lithographic imaging
736	and etch/deposition, etc.
737	
738 •	Tackling challenges related to process tools and core capabilities: [1] These include:
739	 Large-area, cost-effective e-beam patterning tools/capabilities
740	 Plasma etching tools for large-area, uniform R2R processing
741	 Ink jet applicators compatible with wide range of UV monomers
742	 Development of high-quality nickel metal electroforming processes for high aspect ratio,
743	large pattern volume structures
743	 High-durability, low-cost transparent imprinting of molds, or, inexpensive/fast
745	replacement transparent molds
745	
740	
	 Large-area, real-time metrology and process characterization
748	Further developing energing process to de terrende large and processos [1]
749 •	Further developing emerging process tools towards large area processes: [1]
750	 Precision ink jet fluid applicators
751	 Any dot, anywhere; high uniformity and thickness control
752	• Atmospheric plasma etching
753	 Lower-cost surface processing with elimination of vacuum step
754	• R2R-ALD
755	 Precision application of very thin layers at high rates
756	 High conformality; uniform coating of aspect ratios up to 1000:1
757	 High film density, low film stress
758	 Continuous, pinhole-free ultra-thin films
759	
760 •	Developing imprint and web materials: [1] Materials are critical for the extension of R2R
761	manufacturing processes to large area and high throughputs.
762	In nanoimprint technology, the imprint materials need to be developed (especially for UV roll-
763	to-roll imprint). There is also a limited supply of suitable web materials. Examples for a
764	"materials wishlist" include:
765	 UV polymers that resist plasma crosslinking
766	 Transparent conductive polymers having:
767	 Higher conductivity and light transmission
768	 Improved durability/stability
769	 UV curable
770	 Less costly, higher-temp substrates
771	 (>250C; preferably clear)
772	

- Tackling metrology and instrumentation challenges:
- Commercial enterprises which incorporate R2R into their product process routes have serious control issues regarding means to detect, control, and otherwise eliminate potential quality issues within products prior to investing additional value add. Cross-cutting needs include items such as; thickness measurement, inspection for mechanical defects such as pinholes and cracks, measurement of electrical properties such as resistance measurement of surface texture, structure and morphology, inspection for inter-layer delamination and voids, etc. Programs are highly desirable that generically investigate these issues with respect to differences in scale, criticality, application, exsitu measurement while advancing tools and methods for the collection, analysis, storage, and use (either in real time or for later data mining) of high volumes of in-line QC data, and for the integration of these data into process control and feedback systems. Ultimately determinations of means to predict/correlate defects to performance would be one of the prime measureable program metrics.
- Defects are undesirable for printed electronics since they cause open and short circuits, thus destroying the performance of devices. There are several factors that cause defects such as missing nozzles in the print head, particles on the substrate, particles on the screen/stamp, web wander, non-uniform web tension, mis-registration, etc. A few examples of defects are shown in Figure 13.

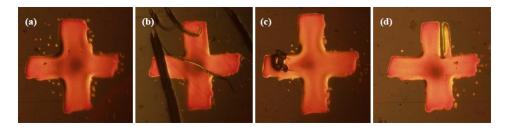


Figure 13 - Optical microscope images of (a) an intended pattern, and (b-d) show defects in the pattern [23]

- Metrology and inspection incorporating in-line optical techniques are presently being developed, but significant challenges remain for monitoring of high throughput processes having nanoscale features. In combination with this, model-based real-time diagnostics and control would complement the development of process modeling and control methods [1].
- For high rate R2R manufacturing, inspection and quality control is a critical area that determines successful outcome. These include defect detection, surface roughness measurement, inspection of layer quality, measurement of electrical properties to

 Metrology and instrumentation challenges include availability of particulate-free high quality substrate, development and implementation of high-speed in-line and off-line inspection and diagnostic tools with adaptive control for patterned and unpatterned material films, development of reliable hardware, etc. These challenges need to be addressed and overcome in order to realize a successful manufacturing process. Due to extreme resolution requirements compared to print media, the burden of software and hardware tools on the throughput also needs to be carefully determined. Moreover, the effect of web wanders and variations in web speed need to accurately be determined in the design of the system hardware and software. [23] Realization of successful metrology and instrumentation by overcoming the challenges for the development of a R2R manufacturing system for flexible electronic systems opens limitless possibilities for the deployment of high performance flexible electronic components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23]. Metrology, standards and inspection requirements for R2R are [24]: defect inspection-pattern defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EER's Quality Control Workhop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Non-contact eddy current measurements for surface sheet resistance of coatings Non-contact eddy current measurements for surface sheet resistance so fo coatings Existing issues with the current quality assurance/quality control techniques for coati	821 822 823	ensure proper functionality, registration control, possibility for repair/correction, product testing, etc. [23].
825 quality substrate, development and implementation of high-speed in-line and off-line 826 inspection and diagnostic tools with adaptive control for patterned and unpatterned 827 material films, development of reliable hardware, etc. These challenges need to be 828 addressed and overcome in order to realize a successful manufacturing process. Due to 829 extreme resolution requirements compared to print media, the burden of software and 830 hardware tools on the throughput also needs to be carefully determined. Moreover, the 831 effect of web wanders and variations in web speed need to accurately be determined in 833 the design of the system hardware and software. [23] 834 Realization of successful metrology and instrumentation by overcoming the challenges 835 for the development of a R2R manufacturing system for flexible electronic 836 opens limitless possibilities for the deployment of high performance flexible electronic 837 components in a variety of applications including communication, sensing, medicine, 838 agriculture, energy, lighting etc. [23]. 840 Metrology, standards and inspection requirements for R2R are [24]: 841 final yield as means to identify defects 842 ecost involveed for now at micron scale for adapting tools to R2R web pla		• Metrology and instrumentation challenges include availability of particulate-free high
826inspection and diagnostic tools with adaptive control for patterned and unpatterned material films, development of reliable hardware, etc. These challenges need to be addressed and overcome in order to realize a successful manufacturing process. Due to hardware tools on the throughput also needs to be carefully determined. Moreover, the effect of web wanders and variations in web speed need to accurately be determined in the design of the system hardware and software. [23]833•834•835for the development of a R2R manufacturing system for flexible electronic systems opens limitless possibilities for the deployment of high performance flexible electronic 		
827 material films, development of reliable hardware, etc. These challenges need to be 828 addressed and overcome in order to realize a successful manufacturing process. Due to 829 extreme resolution requirements compared to print media, the burden of software and 830 hardware tools on the throughput also needs to be carefully determined. Moreover, the 831 effect of web wanders and variations in web speed need to accurately be determined in 832 the design of the system hardware and software. [23] 833 o Realization of successful metrology and instrumentation by overcoming the challenges 834 o Realization of successful metrology and instrumentation by overcoming the challenges 835 of the development of a R2R manufacturing ysstem for flexible electronic 836 opens limitless possibilities for the deployment of high performance flexible electronic 837 components in a variety of applications including communication, sensing, medicine, 838 agriculture, energy, lighting etc. [23]. 840 o Metrology, standards and inspection requirements for R2R are [24]: 841 defect inspection-pattern defects 842 c. characterization/pattern inspection 843 e. Isase scattering/particle size distribution		
828 addressed and overcome in order to realize a successful manufacturing process. Due to 829 extreme resolution requirements compared to print media, the burden of software and 830 hardware tools on the throughput also needs to be carefully determined. Moreover, the 831 effect of web wanders and variations in web speed need to accurately be determined in 832 the design of the system hardware and software. [23] 833 Realization of successful metrology and instrumentation by overcoming the challenges 835 for the development of a R2R manufacturing system for flexible electronic 836 opens limitless possibilities for the deployment of high performance flexible electronic 837 components in a variety of applications including communication, sensing, medicine, 838 agriculture, energy, lighting etc. [23]. 840 o Metrology, standards and inspection requirements for R2R are [24]: 841 defect inspection-pattern defects characterization/pattern inspection 842 characterization/patteri inspection saumary of industry inputs on in-line CC techniques directly from EERE's Quality 843 cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. 844 final yield as means to identify defects	827	
830hardware tools on the throughput also needs to be carefully determined. Moreover, the831effect of web wanders and variations in web speed need to accurately be determined in832the design of the system hardware and software. [23]833•834•835for the development of a R2R manufacturing system for flexible electronic836opens limitless possibilities for the deployment of high performance flexible electronic837components in a variety of applications including communication, sensing, medicine,838agriculture, energy, lighting etc. [23].840•841defect inspection-pattern defects842•843•844•845cost involved for now at micron scale for adapting tools to R2R web platforms846•847•848•849•849•840•841•842•843•844•845•846•847•848•849•849•849•849•849•849•849•840•841•842•845•846•847•848•849•849•840•	828	
 effect of web wanders and variations in web speed need to accurately be determined in the design of the system hardware and software. [23] Realization of successful metrology and instrumentation by overcoming the challenges for the development of a R2R manufacturing system for flexible electronic systems opens limitless possibilities for the deployment of high performance flexible electronic components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23]. Metrology, standards and inspection requirements for R2R are [24]: defect inspection-pattern defects characterization/pattern inspection edefect involved for now at micron scale for adapting tools to R2R web platforms inspected can reach to 1 µm. Asummary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact dy current measurements for surface sheet resistance Non-contact tyray fluorescence (XRF) for composition and also thickness of coatings Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality	829	extreme resolution requirements compared to print media, the burden of software and
832 the design of the system hardware and software. [23] 833 • 834 • 835 for the development of a R2R manufacturing system for flexible electronic systems 836 opens limitless possibilities for the deployment of high performance flexible electronic 837 components in a variety of applications including communication, sensing, medicine, 838 agriculture, energy, lighting etc. [23]. 840 • 841 defect inspection-pattern defects 842 • 843 • 844 final yield as means to identify defects 845 • 846 • 847 • 848 • 849 • 846 • 847 • 848 • 849 • 846 • 847 • 848 • 849 • 849 • 840 • 841 • 842 • 843	830	hardware tools on the throughput also needs to be carefully determined. Moreover, the
 Realization of successful metrology and instrumentation by overcoming the challenges for the development of a R2R manufacturing system of flexible electronic systems opens limitless possibilities for the deployment of high performance flexible electronic components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23]. Metrology, standards and inspection requirements for R2R are [24]: defect inspection-pattern defects characterization/pattern inspection laser scattering/particle size distribution final yield as means to identify defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Existing issues with the current quality assurance/quality control techniques Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 	831	effect of web wanders and variations in web speed need to accurately be determined in
 Realization of successful metrology and instrumentation by overcoming the challenges for the development of a R2R manufacturing system for flexible electronic systems opens limitless possibilities for the deployment of high performance flexible electronic components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23]. Metrology, standards and inspection requirements for R2R are [24]: defect inspection-pattern defects characterization/pattern inspection laser scattering/particle size distribution final yield as means to identify defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact v-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 	832	the design of the system hardware and software. [23]
835for the development of a R2R manufacturing system for flexible electronic systems836opens limitless possibilities for the deployment of high performance flexible electronic837components in a variety of applications including communication, sensing, medicine,838agriculture, energy, lighting etc. [23].840o841defect inspection-pattern defects842characterization/pattern inspection843laser scattering/particle size distribution844final yield as means to identify defects845cost involved for now at micron scale for adapting tools to R2R web platforms846smallest features inspected can reach to 1 µm.847o848Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows:849techniques currently used in industry to identify and quantify defects in materials are:851Vision detection systems for cracks852Fluorescence of functional coatings applied to textiles853Non-contact dydy current measurements for surface sheet resistance854Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings855Photo-imaging for physical defects859Existing issues with the current quality assurance/quality control techniques859Existing issues with the current quality assurance/quality control techniques860Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application861Hardware exists. Main gap is software relevant to specific application <td>833</td> <td></td>	833	
 opens limitless possibilities for the deployment of high performance flexible electronic components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23]. Metrology, standards and inspection requirements for R2R are [24]: defect inspection-pattern defects characterization/pattern inspection laser scattering/particle size distribution final yield as means to identify defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 	834	
837components in a variety of applications including communication, sensing, medicine, agriculture, energy, lighting etc. [23].839		
838agriculture, energy, lighting etc. [23].83908400841defect inspection-pattern defects842characterization/pattern inspection843laser scattering/particle size distribution844final yield as means to identify defects845cost involved for now at micron scale for adapting tools to R2R web platforms846smallest features inspected can reach to 1 μm.8470848Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows:849Techniques currently used in industry to identify and quantify defects in materials are:851Vision detection systems for cracks852Fluorescence of functional coatings applied to textiles853Non-contact eddy current measurements for surface sheet resistance854Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings858Photo-imaging for physical defects859Existing issues with the current quality assurance/quality control techniques850Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application		
839 • Metrology, standards and inspection requirements for R2R are [24]: 841 • defect inspection-pattern defects 842 • characterization/pattern inspection 843 • laser scattering/particle size distribution 844 • final yield as means to identify defects 845 • cost involved for now at micron scale for adapting tools to R2R web platforms 846 • smallest features inspected can reach to 1 µm. 847 • A summary of industry inputs on in-line QC techniques directly from EERE's Quality 848 Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: 849 • Techniques currently used in industry to identify and quantify defects in 850 materials are: 851 • Vision detection systems for cracks 852 • Fluorescence of functional coatings applied to textiles 853 • Non-contact eddy current measurements for surface sheet resistance 854 • Non-contact st-ray fluorescence (XRF) for composition and also thickness of coatings 855 • On-contact x-ray fluorescence (XRF) for composition and also thickness of coatings 858 • Photo-imaging for physical defects 859 • Existing issues with the current quality assurance/quality control techniques <tr< td=""><td></td><td></td></tr<>		
840•Metrology, standards and inspection requirements for R2R are [24]:841•defect inspection-pattern defects842•characterization/pattern inspection843•laser scattering/particle size distribution844•final yield as means to identify defects845•cost involved for now at micron scale for adapting tools to R2R web platforms846•smallest features inspected can reach to 1 µm.847•A summary of industry inputs on in-line QC techniques directly from EERE's Quality848Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows:849•Techniques currently used in industry to identify and quantify defects in materials are:851•Vision detection systems for cracks852•Fluorescence of functional coatings applied to textiles853•Non-contact eddy current measurements for surface sheet resistance854•Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings855•Photo-imaging for physical defects859•Existing issues with the current quality assurance/quality control techniques860•Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application861•Hardware exists. Main gap is software relevant to specific application		agriculture, energy, lighting etc. [23].
841defect inspection-pattern defects842characterization/pattern inspection843laser scattering/particle size distribution844final yield as means to identify defects845cost involved for now at micron scale for adapting tools to R2R web platforms846smallest features inspected can reach to 1 µm.847A summary of industry inputs on in-line QC techniques directly from EERE's Quality848Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows:849Techniques currently used in industry to identify and quantify defects in materials are:851Vision detection systems for cracks852Fluorescence of functional coatings applied to textiles853Non-contact eddy current measurements for surface sheet resistance854Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings855Photo-imaging for physical defects858Photo-imaging for physical defects859Existing issues with the current quality assurance/quality control techniques860Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application861Hardware exists. Main gap is software relevant to specific application		
 k42 characterization/pattern inspection k43 laser scattering/particle size distribution k44 final yield as means to identify defects k45 cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. k47 A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: K49 Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 		
 laser scattering/particle size distribution final yield as means to identify defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 		
 final yield as means to identify defects cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 cost involved for now at micron scale for adapting tools to R2R web platforms smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 smallest features inspected can reach to 1 µm. A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 		
 A summary of industry inputs on in-line QC techniques directly from EERE's Quality Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows: Techniques currently used in industry to identify and quantify defects in materials are: Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
848Control Workshop, which was held in 2013 in Golden, Colorado [22] are as follows:849Techniques currently used in industry to identify and quantify defects in materials are:850materials are:851Vision detection systems for cracks852Fluorescence of functional coatings applied to textiles853Non-contact eddy current measurements for surface sheet resistance854Non-contact optical measurements for band gap and relative thickness of coatings856Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings858Photo-imaging for physical defects859Existing issues with the current quality assurance/quality control techniques860Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application862Hardware exists. Main gap is software relevant to specific application		
 849 Techniques currently used in industry to identify and quantify defects in materials are: 851 Vision detection systems for cracks 852 Fluorescence of functional coatings applied to textiles 853 Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings 856 Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings 858 Photo-imaging for physical defects 859 Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 862 Hardware exists. Main gap is software relevant to specific application 		
 850 materials are: 851 Vision detection systems for cracks 852 Fluorescence of functional coatings applied to textiles 853 Non-contact eddy current measurements for surface sheet resistance 854 Non-contact optical measurements for band gap and relative thickness of coatings 856 Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings 858 Photo-imaging for physical defects 859 859 Existing issues with the current quality assurance/quality control techniques 860 Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 862 		
 Vision detection systems for cracks Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 Fluorescence of functional coatings applied to textiles Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 Non-contact eddy current measurements for surface sheet resistance Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 Non-contact optical measurements for band gap and relative thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 855 of coatings 856 Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings 857 of coatings 858 Photo-imaging for physical defects 859 Existing issues with the current quality assurance/quality control techniques 860 Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 862 Hardware exists. Main gap is software relevant to specific application 		
 Non-contact x-ray fluorescence (XRF) for composition and also thickness of coatings Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 857 of coatings 858 Photo-imaging for physical defects 859 Existing issues with the current quality assurance/quality control techniques 860 Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application 862 Hardware exists. Main gap is software relevant to specific application 		-
 Photo-imaging for physical defects Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 Existing issues with the current quality assurance/quality control techniques Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		-
 Lack of standards. A few companies sell cameras and algorithms, but not necessarily tuned to the application Hardware exists. Main gap is software relevant to specific application 		
 861 not necessarily tuned to the application 862 Hardware exists. Main gap is software relevant to specific application 		
• Hardware exists. Main gap is software relevant to specific application		
• Need to be able to scan for the composition of coatings (for multi-		
864 material coatings) and physical defects across full width and length of		
865 web while web is in motion		
866 Measurements needed for in-line quality control that current techniques do not		
867 address		

868	 Physical defect density and/or pinhole density
869	Band gap measurements
870	 Surface sheet resistance of coatings
871	Optical transmission
872	 Relative thickness of coatings across and along the length of the web
873	Material composition measurements
874	 Networking-cloud data transmission
875	
876	2.6. Emerging Processes and Tools for R2R
877	2.6.1. Atomic Layer Deposition (ALD)
878 879	ALD is a thin film deposition technique in which films are grown by the sequential pulsing of chemical precursors onto the surface of a substrate. A typical process sequence involves introduction of precursors

itroduction of precursor face of a substrate. typical process sequence 880 A, followed by a system purge, then introduction of precursor B, followed by another system purge, 881 after which the steps are repeated. The precursor reactions on the substrate surface lead to the growth 882 of the thin film on a layer-by-layer basis, with the resulting film thickness controlled by the number of 883 cycles of the process sequence. As the deposition process is self-limiting, the films are extremely 884 uniform, pinhole free, and exceptionally conformal. ALD is capable of depositing a range of metal oxide 885 films, as well as a limited number of metal coatings, and has the further advantage of relatively low-886 temperature processes and reasonably low-cost precursors for most applications. As a result, ALD is 887 finding traction in the semiconductor industry, and has further been scaled to large-area substrate 888 processes for thin film photovoltaics and displays where the metal oxide coatings yield superior barrier 889 coatings and dielectric films [1].

890

2.6.2. Potentiometric Stripping Analysis for Electroplated Alloys

891

892 Electroplating represents an additive, solution-based deposition process suitable for R2R platforms for a 893 range of metals and alloys. A key challenge for continuous, high-speed coating systems is the control of 894 stoichiometry and the depletion the plating baths in web-based systems. The potentiometric stripping 895 analysis (PSA) techniques precisely control both stoichiometry and uniformity of metal and alloy 896 coatings on flexible webs. Keys to maintaining sufficient process control in the electroplating steps 897 included keeping the solution at the work surface fresh and evenly biased by agitating the bath, 898 providing adequate circulation, further utilizing an inert environment such as an argon blanket to 899 minimize the effects of oxidation, and utilizing a separate anode for precise control of field distribution 900 [1].

901 902

2.6.3. High Temperature R2R Processes

903 ORNL is conducting the research in the development of high-temperature R2R processes suitable to 904 create crystalline, high-performance semiconducting materials. The high-temperature process capability 905 can exceed 1200°C through the use of a high-temperature metal or suitable substrate; calendaring of 906 thin film coatings then occurs, followed by a thermal pressing step. Because typical processes tailor a 907 series of functional layers, inter-diffusion becomes a significant concern. This issue is resolved by 908 depositing a stack of buffer layers to provide the required crystal orientation that include deposition of a 909 diffusion barrier and then active layer coating. The high-temperature R2R processes can be used to 910 develop hybrid solution-based approaches as well. The high-temperature processes are suitable for a 911 range of thin film crystalline materials, including silicon for solar PV, diamond, and other 912 semiconductors. This R2R process capability opens up opportunities for large-area, high-quality 913 semiconductors having electronic transport properties approaching those of bulk materials, thereby 914 enabling high-performance electronic devices and systems [1].

2.6.4. Standards Development

917 918 Standards are an important aspect of the successful commercialization of any product, and typically are 919 underestimated. Benefits of standards include building end user confidence, creation of a common 920 language between producers and users, promotion of product compatibility and interoperability, 921 overcoming trade barriers to open markets, and fostering diffusion and adoption of technology. As 922 printed electronics and R2R manufacturing transcend from fundamental science to laboratory-scale 923 production platforms within academia and industry, the transition to pilot-scale production is hampered 924 by several factors that can benefit from standards. The resulting delay in the commercialization cycle 925 includes losses resulting from incoming materials variations, process technologies, process tolerances, 926 equipment and operator inconsistencies, and lot-to-lot variations, making it extremely costly and 927 difficult to scale to R2R production capacity [1].

928

929 930

2.7. Key Technology/Application Opportunity Areas

2.7.1. Membranes

931 Areas of interest might include (but not limited to); high pressure "ceramic" membranes, indoor air 932 quality and dehumidification membranes for applications in buildings, other water processing, gas 933 separations for natural gas processing and CO_2 capture application s (CO_2/N_2 , CO_2 , H_2 , and CO_2/CH_4), and 934 liquid/gas separation membranes (CO_2 loaded solvents), forward osmosis capacitive polarization 935 membranes, and other multilayer systems such as those used in battery applications, i.e. VRF which 936 support high permeability rates, resist reject material "buildup" and are environmentally "friendly". Current production cost of membranes is 2 Current production cost of membranes is 2 Current production cost of membranes is 2 937 938 industry are needed to reduce costs by at least 50%. Current membrane market is \$16.5B globally – 939 United States demand is approximately \$1.7B total - Liquid separation is \$1.5B and ~\$0.15B for gas 940 separation. Expected to rise ~7% per year. Global membrane demand is expected to be \$25.7B in 2017 941 and continue to rise ~10% per year [25].

942 **2.7.2.** Advanced Deposition Processes

943 Formatted, higher quality depositions are needed. Equipment needs to support formats sufficient to 944 meet microelectronics to building sector requirements. Investigations/development will focus on tools 945 to feed solutions and slurries at high rates while controlling solution rheologies; web properties, motor 946 controlsfor web speed control, tensioning, material "take-up", post formatting; metrological 947 instrumentation; control feedback and process adjustment; materials drying; ventilation and effluent 948 treatments, and incorporation of concurrent/simultaneous processes. Emphatically, all of the 949 aforementioned is needed at all-size scales, i.e. from the nano/atomic scale through thin-film to thick-950 film size-scale.

951 **2.7.3.** Flexible Electronics

952 An intrigue space is R2R additive manufacturing for EMS. The technology applications are well defined, 953 most of the materials are well defined in manufacturing, mostly the technologies, with exception of 954 interconnects that are mature (MRL 4-5). However, government investments are necessary to reduce 955 risk for industry to participate. EMS is a \$300B/year industry. The market is in printed circuit board 956 population with Si CMOS and passive components. On a limited basis, R2R is used in single chip 957 integration for smart labels (RFID tags and antennas), such as products offered by Muhlbauer High Tech 958 International [26]. Another area of possible manufacturing development involves OLEDS which can be 959 processed on flexible substrates [27], as shown in Figure 14. Systems have been developed which have 960 exhibited a brightness as high as 10,000 candela per square meter. DOE projects the benefits of 961 replacing traditional systems with phosphorescent OLED lighting, in the time frame of 2012 to 2018, as

- 962 reducing energy use by 0.22 quadrillion Btu's, saving domestic consumers \$20 billion and reducing
- 963 environmental pollution emissions by 3.7 million metric tons [28].
- 964

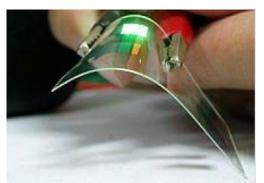


Figure 14 - Demonstration of a flexible OLED device. Photo: General Electric

967 968 The second area of interest focuses on larger format flexible displays, detectors and other sensors, such 969 as used for neutron and other E-M arrays. This path will be to move from plate-to-plate standard 970 lithography as used in the industry to continuous R2R processing. This approach leverages \$90M of 971 existing U.S. Army investments, and \$1T+ of industrial private sector investments in traditional flat-panel 972 glass manufacturing. The current TRL levels are 3-4 for emerging applications, TRL 5-6 for the maturing 973 flexible digital x-ray technology. The MRL level is 5, with development necessary to broaden the 974 application space, reduce cost and improve yield. Here the work would attempt to merge traditional 975 processes with some R2R technology. If a major thrust involves sensors, opportunity to continue 976 development of materials (incorporating new material sets, enhanced efficiency of traditional types, i.e. 977 substitutional elements, enhanced process, etc.) will be investigated. Sensor efforts include from 978 MRL/TRL 1 to fully commercialize. Those efforts within the MRL/TRL 4 to 7 include those that would 979 serve to incorporate program information to feed MetaData collection, design of more 980 efficient/selective devices, develop imbedding processes within other materials-assemblies, means to 981 enhance signal processing, and collected data "Cyber Security". This latter being needed as users will 982 need to collect data remotely to gage quality, state-of-the condition to enable state of process or mean-983 time to failure, response characterization, etc. via the "internet cloud" to be successful. If one considers 984 thin-film MEMS sensors and devices within the scope of this sector, the market could exceed \$1 trillion. 985 986 A third area would be to focus on the advancement of materials with associated equipment to enable 987 commercialization of NIL and patterning with 50 to 100nm print resolution at process rates of 3 to 5 988 meters per minute. Fourthly, flexible electronics need to include investigation of lighting technologies. 989 This would include moisture and environmental barrier materials/layers with ALD of LED and OLED 990 technologies with associated packaging systems, which are fabricated in multilayer fashion to achieve a 991 hermetic, moisture-proof package. 992 993 The current research work is focused on the following topics: [29] Developing roll-to-roll manufacturing of thin film electronics on low-cost flexible substrates 994 995 using Pulse Thermal Processing (PTP) technologies coupled with non-vacuum low temperature 996 deposition techniques. 997 Developing non-vacuum, large scale deposition and processing techniques for nanoparticle-998 based inks and pastes that reduce cost and energy requirements associated with processing of 999 thin film electronics.

- 1000 Ink development and annealing studies to increase the crystallinity and photo luminescent • 1001 efficiency of Zinc-Gallate coatings.
 - 2.7.4. Battery Technology

1004 Including existing agency investments and commercial development results, work should focus on a 1005 wide range of battery chemistries, i.e. Li-ion, Zinc-polymer, Li/CFx, Vanadium Redox Flow (VRF) systems, 1006 and advanced alkaline systems. Continuous materials deposition on webs to build the "multi-layer" 1007 configuration using tape cast, screen print, vapor or wet chemical deposition or evaporative/sputter techniques could be included. Of special interest would be deposition of carbon nano-tubes and 1008 1009 whiskers on graphene for certain applications.

1010

1013

1014

1015

1018

1019

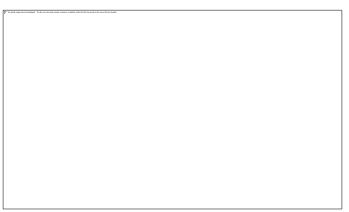
1002 1003

1011 The current research work to apply R2R processes in flexible thin-film battery manufacturing is focused 1012 on the following topics: [30]

- Reducing excessive scrap rates of electrode coatings.
- In-line quality measurement and control For example: In-line laser sensing for thickness • monitoring, in-situ materials diagnostics with ex-situ structural characterization.
- 1016 • Reducing manufacturing as well as associated system cost by implementing in-line Non-1017 Destructive Examination (NDE) and QC].
 - Scaling-up, Industrial issues of yield and throughput.

2.7.5. PEM Fuel Cells

1020 1021 The manufacture of fuel cell stack components utilizing continuous, high volume, lower cost process 1022 technologies is needed. Current R2R technology and methods need to replace the manual preparation 1023 of layers, such as painting catalyst ink by hand onto decals that are then thermally pressed onto 1024 membranes. The process should also address high-speed sealing of assemblies which can be 1025 accomplished using R2R processes. Figure 15 shows an approach that WL Gore & Associates [31] is 1026 working on to coat electrodes directly onto membrane material saving steps and material thus saving 1027 money. 1028



1029 1030

Figure 15 - Approach to coat electrodes directly onto membrane material saving steps and material

1031

1032 In 2012, the domestic fuel cell and hydrogen energy industry was expected to produce \$785 million in 1033 revenue [32]. Funding from DOE EERE for hydrogen and fuel cell R&D has played a critical role to enable

1034 this emerging fuel cell industry. According to Bloomberg New Energy Finance [33], DOE funding was

1035 approximately equal to venture capital and private equity investment in the United States in 2011. EERE

- 1036 funding has led to more than 450 patents, 40 commercial technologies, and 65 emerging technologies
- 1037 for hydrogen production and delivery, hydrogen storage, and fuel cells.

2.7.6. Photovoltaics

 In addition to efficient processing, efficient process control during manufacture is required, and new materials and processes are urgently needed. Some of the most important materials and processes are those that will enable the printing of semitransparent electrodes and complete processes that are built around enabling complete fabrication of efficient solar cells. The materials and processes should of course give access to organic photovoltaic (OPVs) that provide operational stability of more than 10 years and they should be efficient (> 10 %). A particular requirement to the OPV is that it has as thin an outline as possible with low materials consumption, to achieve a low embodied energy. The processing should not be environmentally harmful and should, through use of the lowest possible temperatures, require a very low input energy for manufacture. This will enable short energy payback times. Manufacture of the entire solar cell stack at an overall speed of > 10 m/min will enable the manufacture of a daily energy production capacity of more than 1 gigawatt peak and thus, in principle, fully address mankind's future energy needs [34]. Figure 16 illustrates the assembly of a scalable, encapsulate, large area, flexible, organic solar cell produced by a R2R process. [35]

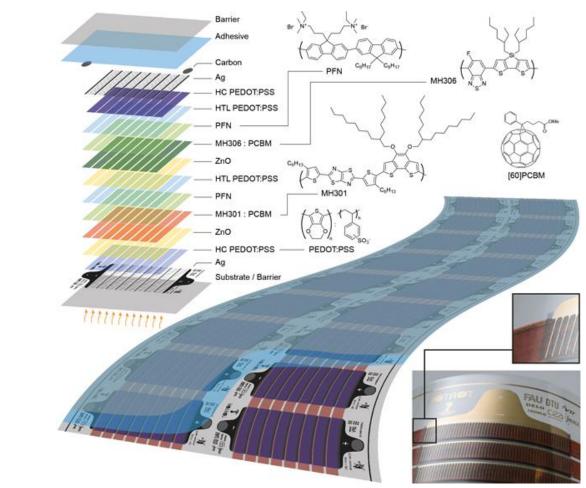


Figure 16 - Scalable, ambient atmosphere roll-to-roll manufacture of encapsulated large area, flexible organic tandem solar cell modules [35].

- The scientific thrust should be with the final form and processing methods in mind and not as it
 has been until now with a blind focus on high performance in an often unrealistic and not
 scalable setting [35].
- The active materials and inks needs to be developed specifically with the thermo-mechanical properties of the multi-layer structure in mind. The complex multi-layer structure with different thermal expansion coefficients and moduli for the individual layers and different adhesion energies at each interface are likely to present an enormous challenge for the manufacture of a robust flexible tandem organic solar cell [35].
- Research efforts are needed on the control of film thickness and especially the evenness of the dry films for the multi-layer stack through proper ink design. This involves control of viscosity, ink stability over time, ink rheology during deposition, ink rheology during drying (i.e. heating and up-concentration of solutes in the wet film), wetting behavior during deposition and drying, control over morphology formation and of course it must all work in air [35].
- 1088 2.7.7. Metrology and Quality Systems 1089 1090 Commercial enterprises which incorporate R2R manufacturing into their processes must 1091 detect, control, and otherwise eliminate potential quality issues within products. 1092 1093 Technology development needs include inspection for mechanical defects such as pinholes • 1094 and cracks, measurement of electrical properties such as resistance measurement, and 1095 inspection for inter-layer delamination and voids. 1096 1097 All data would be integrated into process control and feedback systems. These technologies 1098 will be used to correlate defects to performance. **Embedded Thermal Energy** 1099 2.4.1.1. 1100
 - There is a need to develop R2R additive manufacturing for electronics applications such as larger format flexible displays, detectors, and stretchable/conformable sensors.
 - This technology will lead to a fundamental change for manufacturing these systems from plate-to-plate standard lithography to continuous R2R processing.

2.8. Technology Roadmaps Applicable to R2R Manufacturing

1106 1107

1101

1102 1103

1104

1105

1075

1081

1087

1108 R2R is a type of process, not a technology, and therefore no specific technology roadmap exists for 1109 developing R2R processes in general; instead, roadmaps exist for specific technologies that would use a 1110 R2R process as the manufacturing method. R2R processes can be improved by insertion of technologies that make the process more efficient and less costly. The International Electronics Manufacturing 1111 1112 Initiative (iNEMI) developed a technology roadmap for flexible electronics that addresses materials 1113 (nanoparticle suspensions, particle blends, and small molecular solutions), printing technologies (contact 1114 and non-contact), and processes (roll to roll, roll to sheet, and sheet). [36] In the United Kingdom, the 1115 Centre for Process Innovation developed their technology roadmap to expand R2R and encapsulation

1116 processing technologies to target the development of flexible optoelectronic devices for the emerging

- 1117 printed electronics markets and to address many of the challenges encountered in scaling up emerging
- 1118 technologies to commercialization by adopting R2R processing techniques.[37]

1119 From an industry perspective, Baker [™] Wet Process Equipment has developed a technology roadmap to

- 1120 understand and manage the issues associated with conventional versus R2R processing for
- 1121 manufacturing flexible printed circuits. [38] Their roadmap focuses on the core of current manufacturing
- 1122 trends toward producing thinner, lighter and higher density printed circuits by use of effective handling
- and processing of a thin core material. R2R processing equipment will need to focus on the smooth, yet
- 1124 firm, transport of films through various wet processes in both a horizontal and vertical plane and will
- 1125 require "next generation" spray- or immersion-type technologies. Flexible printed circuit fabrication
- 1126 using batch processing and antiquated rigid-panel processes is responsible for the failure to produce the
- 1127 necessary technologies in the last century and will be superseded by R2R technology in the future. [39]
- 1128 Additionally, the National Aeronautics and Space Administration (NASA) has drafted integrated
- technology roadmaps for 14 Space Technology Areas, which includes "pull" and "push" technology
- 1130 strategies and considers a wide range of pathways to advance their current capabilities in space.
- 1131 Technology Area 12 addresses materials, structures, mechanical systems, and manufacturing. Although
- 1132 R2R is not specifically addressed as part of the roadmap, several of the technologies and processes, such
- 1133 as hybrid laminates, polymer matrix composites, multi-functional thin films, flexible materials for entry-
- descent-landing, photovoltaics, lightweight aluminized thin film systems for solar sails and large ultra-
- light precision optical materials are all directly applicable to R2R manufacturing.[40]

11362.9. Workshops on R2R Processes and Manufacturing

1137 Workshops are not held specifically on just R2R manufacturing. Usually a workshop is convened on a technology area such as Nanofabrication Technologies for R2R Processing [second ref] or the DOD and 1138 1139 DOE Manufacturing Innovation Topics Workshop [third ref] where R2R manufacturing is an agenda topic 1140 or a separate breakout session. Discussions typically focus on using a R2R process for coating of polymer 1141 films, device level patterning, imprint lithography methodology, patterning limitations, and NIL for R2R 1142 processing of nanotechnologies. [1] Workshops also address programmatic issues for R2R manufacturing 1143 such as R2R process technology needs; manufacturing challenges, and investments; process deficiencies 1144 and metrological needs; and quality systems and synergy. [41] Workshops are held annually on 1145 nanomanufacturing that provide opportunities to share information on emerging processes and scaled 1146 manufacturing platforms where R2R may have a role. [42] [43] They can also focus on specific 1147 technology areas that have immediate applications to clean energy initiatives such as biomass indirect 1148 liquefaction that focuses on pathways that convert biomass-based synthetic gases to liquid 1149 intermediates. [44] Inevitability, the common areas of interest lie in overall technology needs, 1150 manufacturing challenges, and investment levels.

- 1151
- 1152 1153

3. Risk and Uncertainty, and other Considerations

1154 3.1. Risks and Uncertainties of Using R2R Processes and Manufacturing

1155 The risks with using R2R processes are defined in the challenges. R2R manufacturing is not ideal for 1156 every type of material manufacturer, but it is ideal for thin and thick film materials with large areas that are required for high volume production with minimal defects and waste. R2R processes, in general, are
energy efficient and environmentally friendly. However, as with any type of manufacturing, there are
associated risks and uncertainties.

1160 High Startup Costs - A combination of high costs and poor availability of production tools are • 1161 hindering the adoption of roll-to-roll manufacturing. For example, setting an active-matrix 1162 flexible organic light-emitting diode (OLED) substrate line amounted to roughly \$177 per square 1163 foot. The cost of tooling a passive-matrix polymer light-emitting diode (PLED) line is far less, at 1164 \$45 per square foot. Still, the long-term promise of roll-to-roll manufacturing is propelling it to 1165 the forefront of flexible substrate R&D activity. The Center for Advanced Manufacturing 1166 (CAMM), Binghamton, NY expanding its tooling capability to actively research R2R 1167 manufacturing for emerging technologies such as large-area LED lighting, photovoltaic cells on 1168 plastic, low-cost RFID tags, and lightweight electronics and packaging platforms on rugged, 1169 flexible substrates. Also, scientists at Hewlett-Packard Laboratories and Iowa, Thin Film 1170 Technologies, are developing large-area arrays of thin-film transistors on polymer substrates 1171 using R2R techniques. The approach combines plasma deposition and etching with self-aligned 1172 imprint lithography to produce a cost effective end product. [45] Further research in specific 1173 applications that employ R2R processes will provide the data needed to reduce the costs of 1174 startup.

• Speed of High Volume/Large Area Process vs Low Volume/Small Item Stand-Alone Process -

1177 The speed and capacity for R2R manufacturing versus a batch process is dependent on the 1178 material requirements for the end product and is directly related to costs. As an example, if an 1179 assumption is made that conventional operations such as lithography, etching and sputter 1180 deposition are used in the R2R process, and 1000-feet by two-feet rolls of polymeric substrate 1181 are used to make a final product of 3.25-inch by 3.25-inch LED display on an 18-inch by 24-inch 1182 format, then the cost per square foot of active and passive matrix displays are expected to 1183 decline with increases of volume. Indeed, studies have shown that the minimum efficient scale 1184 for the operation of a R2R display manufacturing facility is around 20,000 square feet per week. 1185 Many markets and application areas could support a plant operating at this capacity if the 1186 displays could be sold into these markets at a sufficiently high volume to sustain the 1187 manufacturing operation. If the plant operated at a capacity of 100,000 square feet per week 1188 over a two-year period, the cost of producing LED displays would be about half the cost of a 1189 display produced by a conventional stand-alone batch manufacturing approach. Nearly every 1190 model in the display industry predicts that a R2R manufacturing facility could offer significant 1191 cost savings if it can be integrated successfully. [46]

1192

1175

Material Variations/Tolerances/Lot Variations/Scrap - Variations in substrates and production
 lots of the end products from R2R manufacturing can be caused by several factors depending on
 the materials being used, the machinery involved, the control of the web, and the process(es)
 employed (lithography, deposition, etc.) just to name a few. Even the configuration of the rollers
 (double side mounted or cantilevered) will produce variations. In some applications such as thin

1198films and nano-materials, the tolerances must be closely controlled in order to get a quality end1199product. If tolerances and variations are significant, then the R2R process can result in a lot of1200scrap and waste material that may not be recyclable. This also adds to the cost of manufacture.1201As the R2R process becomes more adapted to the anomalies in the initial production phases, the1202material and lot variations are usually reduced and the end products are well within tolerances.1203Research is needed on various types of instruments can be incorporated into the R2R process to1204further reduce variations and eliminate scrap.

1206 **Metrology** - As previously discussed in this section, the success of employing a R2R process in 1207 manufacturing a specific technology is heavily dependent on process and cost control. At high 1208 rates of R2R manufacturing, metrology is needed to address defects (from static buildup and 1209 missing or disconnected patterns), quality of substrate, registration (pattern position), and in-1210 line and off-line optical inspection for quality control. [47] This can go beyond just looking for 1211 material defects such as pinholes, non-uniform thickness, and impurities. As an example, at the 1212 end of processing polymer solar cells using roll-to-roll methods, one ends up with a roll of 1213 material. While some testing can be carried out during the processing of the individual layers, 1214 the functionality of the solar cell itself, i.e., the production of electrical energy upon being 1215 subject to illumination, has to be carried out at the very end, on the very roll that is the end 1216 product. Inline monitoring techniques are useful for guiding the process, but they cannot 1217 guarantee the final performance. Therefore R2R instrumentation is also needed to test 1218 functionality. The techniques that have proven useful for process control are the camera techniques, providing two-dimensional information using transmission, reflection, and dark field 1219 1220 imaging of the printed or coated films, and revealing detail on film thickness variations, 1221 registration, and particle detection. These techniques are non-contact techniques and apply to 1222 individual layers during manufacture. Methods such as light beam induced current mapping, 1223 dark lock-in thermographic imaging, electroluminescense imaging, and photoluminescence 1224 imaging are being used successfully today in R2R manufacturing of solar cell materials. [48]

1226DOE's Manufacturing Demonstration Facility (MDF), established at ORNL, provides unique1227capabilities to assist industry in adopting new manufacturing technologies to reduce life-cycle1228energy and greenhouse gas emissions, lower production cost and create new products and1229opportunities for high paying jobs. [49] The MDF can be a tremendous asset in addressing the1230above risks and uncertainties.

- Proprietary Information and Intellectual Property Successful implementation of R2R
 processes within the manufacturing industry will require information exchange, resource
 partnering, open discussion of ideas, discoveries, and best practices. Key challenges exist in
 providing an open forum for networking while protecting the proprietary information and
 intellectual property of the community
- 1238 Technology Characteristics That Impact Policy

1205

1225

1231

1239	
1240	The President's 2012 National Strategic Plan for Advanced Manufacturing emphasized the need
1241	for increased R&D on advanced materials and innovative manufacturing technologies that have
1242	the potential to reduce U.S. manufacturing energy use while enhancing product quality and
1243	shortening design cycle times. [50] DOE is responsible for executing programs resulting in the
1244	development of competitive new manufacturing processes for U.S. industry to provide state-of-
1245	the-art technologies in advanced vehicles, biofuels, solar energy and other clean energy
1246	technologies. Technologies areas, such as advanced lightweight materials, membranes and TFTs,
1247	have an immediate use for improving products for clean energy applications and are
1248	appropriate for manufacturing using R2R processes.
1249	

1250 4. Sidebars: Case Studies

1251



1252 4.1. Thin-Film Solar Cell Efficiency Record Set By First Solar (Again) [51] [52]

1253

- Figure 17 First Solar, Inc. Solar Cell Array
- 1255 Working with DOE National Renewable Energy Laboratory (NREL), First Solar, Inc. set a world record in
- 1256 2013 for CdTe PV solar cell conversion efficiency, achieving 20.4 percent conversion efficiency. The U.S.-
- 1257 based company recently announced that a cell manufactured at its manufacturing factory and R&D
- 1258 center achieved an efficiency of 21%, the highest on record by a non-concentrating cadmium-telluride
- 1259 (CdTe) cell. Improvement in CdTe PV performance was demonstrated at a rate that dramatically
- 1260 outstrips the trajectory of conventional multicrystalline silicon technologies, which have already
- 1261 plateaued near their ultimate capabilities. First Solar, Inc. has also gone a notch up on multi-crystalline
- 1262 silicon cells, whose efficiency peaked at 20.4% in 2004.
- 1263 The encouraging fact about the cell is that it has been constructed using processes, such as roll-to-roll,
- and materials designed for commercial-scale manufacturing, thus making is possibly easier for First Solarto quickly switch to the cell's mass production.

- 1266 First Solar, Inc. also synergy realized a synergy by partnering with GE Global Research in 2013 with
- 1267 consistent and strong investments in R&D. The advanced technologies and processes developed for the
- 1268 CdTe PV solar cell are already being commercialized and will positively impact performance of future
- 1269 production solar cell modules and power plants.
- 1270 First Solar has continued to transfer success in R&D into commercial modules, increasing its average
- 1271 production module efficiency to 13.4 percent in the fourth quarter of 2013, up 0.6 percent from 12.9
- 1272 percent in the fourth quarter of 2012. The company's lead line was producing modules with 13.9
- 1273 percent average efficiency at the end of 2013. [51]

1274 4.2. Commercial Buildings Integration of Energy Saving Window Coatings [52] [53]



1275

1276 The DOE Building Technologies Office (BTO) works with the commercial building industry to accelerate 1277 the uptake of energy efficiency technologies and techniques in both existing and new commercial 1278 buildings. By developing, demonstrating, and deploying cost-effective solutions, BTO strives to reduce 1279 energy consumption across the commercial building sector by at least 1,600 TBtu. [52] The BTO has 1280 several projects in R&D for electrochromic windows, high-insulating windows, and nano-lens window 1281 coatings for daylighting and low-e storm windows adoption. [53] R2R manufacturing is used for products 1282 like 3M[™] window films block up to 60% of the sun's heat. Transparent, rather than dark or shiny, costs 1283 of cooling are saved without sacrificing passive lighting or views. [54]

1284

1285 **5. References**

- 1286
- 12871. Jeffrey D. Morse, "Nanofabrication Technologies for Roll-to-Roll Processing", Report from the1288NIST-NNN Workshop, September 2011.
- Jurgen Willmann, Daniel Stocker, and Edgar Dorsam, "Characteristics and evaluation criteria of substrate-based manufacturing. Is roll-to-roll the best soltion for printed electronics?", Organic Electronics, 15 (2014), 1631-1640.
- Bae, Kim, Lee, Xu, Park, Zheng, Balakrishnan, Lei, Kim, Song, Kim, Kim, Ozyilmaz, Ahn, Hong,
 lijima. 2010. *Roll-to-roll production of 30-inch graphene films for transparent electrodes*. Nature
 Nanotechnology. DOI: 10.1038/nnano.2010.132

DRAFT - PRE-DECISIONAL - DRAFT

- 12954. A. Gregg, L. York and Mark Strnad, "Roll-to-Roll Manufacturing of Flexible Displays." In Flexible1296Flat Panel Displays, ed. G.P Crawford. Wiley, 2005. pp. 410-445.
- Flexible Electronics Market by Components, Circuit Structure Application, & by Geography Analysis & Forecast to 2014 2020, By: marketsandmarkets.com, Publishing Date: July 2014,
 Report Code: SE 2571.
- Markus Hosel, Roar Sondergaard, et.al., Comparison of fast roll-to-roll flexographic, inkjet,
 flatbed, and rotary screen printing of metal back electrodes for polymer solar cells, Advanced
 Engineering Materials Communication, Volume 15, Issue 10, June 2013.
- 1303 7. Michael P. C. Watts, Impattern Solutions, "Advances in roll to roll processing", 2007.
- 13048.Yoon, Deokkyun, Kim, Dong-Soo, "Roll to Roll Printing in Electronic Applications." May 2011,1305http://industrial-printing.net/content/roll-printing-electronics-applications
- Journal of Polymer Science Part B: Polymer Physics, <u>Volume 51, Issue 1, pages 16–34, 1 January</u>
 2013, <u>http://onlinelibrary.wiley.com/doi/10.1002/polb.23192/full</u>
- 1308 10. Evan Schwartz, Roll to Roll Processing for Flexible Electronics, Cornell University, 2006.
- 1309 11. Carl Taussig, et.al. Roll-to-Roll Manufacturing of Flexible Displays, Hewlett-Packard Company,1310 Palo Alto, CA.
- Alejandro De la Fuente Vorbrock, Roll Printed Electronics: Development and Scaling of Gravure
 Printing Techniques, EECS Department, University of California, Berkeley, Technical Report No.
 UCB/EECS-2009-191, December 29, 2009
- 13. Dr. Steve Carlson, Optodot Corporation 14 May 2012, Innovative Manufacturing and Materials
 1315 for Low-Cost Lithium-Ion Batteries,
 1316 http://energy.gov/sites/prod/files/2014/03/f9/es136 carlson 2012 p.pdf
- 1317 14. Onoda, George Jr., and L. Hench, Ceramic Processing Before Firing, John Wiley and Sons, New 1318 York, pp.426-428, 1978.
- 1319 15. Campbell, Stephen A., The Science and Engineering of Microelectronic Fabrication, Oxford1320 University Press, New York, 1996.
- 1321 16. Center for Hierarchical Manufacturing, Nano-enabled Roll to Roll Manufacturing Research,
 1322 University of Massachusetts (Amherst), Amherst, MA
- 132317. Chin, Spencer. "Roll-to-roll flexible displays still far from reality." EETimes Online, February 10,13242006.
- 1325 18. Key Patent Report Flexible Roll-to-Roll Technology -2013, Information Handling Services, Inc.
 1326 (HIS) Patent analysis: Flexible roll-to-roll processing, <u>http://electroiq.com/blog/2013/02/patent-</u>
 1327 analysis-flexible-roll-to-roll-processing.

19. Tulis, Robert W., et al, Review of Defense Display Research Programs, AFRL, Wright-Patterson 1328 1329 AFB, OH 45433-7022, 18 May 2001 1330 20. Forsythe, E., et al, Next Generation Highly Conducting Organic Films Using Noval Donor-acceptor Molecules for Opto-electronic Applications, ARL-TR-4853, June 2009 1331 1332 21. US Army, RDECOM, ARL, Electronic Manufacturing services, 2013 1333 22. EERE Quality Control Workshop Final Report - Proceedings from the EERE Quality Control 1334 Workshop, in support of the DOE Clean Energy Manufacturing Initiative, Golden, Colorado, 1335 December 9–10, 2013. 1336 23. Metrology and instrumentation challenges with high-rate, roll-to-roll manufacturing of flexible electronic systems, Harish Subbaraman, Xiaohui Lin, et.al. Proc. SPIE 8466, Instrumentation, 1337 1338 Metrology, and Standards for Nanomanufacturing, Optics, and Semiconductors VI, 846603, 1339 October 11, 2012. 1340 24. Synergies in Nano-Scale Manufacturing & Research, A two day workshop held at Cornell 1341 University, Ithaca, NY, January 27-29, 2010. 1342 25. World Membrane Separation Technologies, Industry study with forecasts for 2017 and 2022, 1343 The Freedonia Group. Available at 1344 http://www.freedoniagroup.com/brochure/30xx/3006smwe.pdf. 1345 26. http://www.muhlbauer.com/ 27. Wikipedia, OLED, http://en.wikipedia.org/wiki/OLED 1346 1347 28. U.S. DOE, SBIR ADVANCES, New OLED Lighting System Shine Bright, Save Energy, 2013 1348 29. Chad Duty, Pooran Joshi, and Panos Datskos, MDF Roll-to-Roll, Quarterly Progress Report, July 1, 2013. 1349 1350 30. David Wood, "Roll-to-Roll Electrode Processing and Materials NDE for Advanced Lithium 1351 Secondary Batteries", May 2012. 1352 http://www.abr.anl.gov/pdfs/2012 presentations/es165 daniel 2012 o.pdf 1353 31. http://www.gore.com/en xx/products/electronic/fuelcells/index.html 1354 32. DOE EERE, 2012 Fuel Cell Technologies Market Report, DOE/EE-0973, October 2013 1355 33. http://www.bloomberg.com/quote/FCEL:US 34. Roar Sondergaard, et. al., "Roll-to-Roll fabrication of polymer solar cells", Materials Today, Jan-1356 1357 Feb 2012, Volume 15, Number 1-2, Pages 36-49.

- 1358 35. Thomas R. Anderson, et. al., "Scalable, ambient atmosphere roll-to-roll manufacture of
 1359 encapsulated large area, flexible organic tandem solar cell modules", Energy & Environmental
 1360 Science, 2014, Volume 7, Pages 2925-2933.
- 1361 36. iNEMI Technology Roadmaps, January 2011
- 1362 37. "Centre for Process Innovation sets out their technology roadmap", OSA Direct website,
 1363 February 11, 2014
- 1364 38. Baker[™] Wet Process Equipment White Paper on Manufacturing Flexible Printed Circuits, 2006
- 1365 *39. Ibid.*
- 40. Piacik, Bob; Vickers, John; Lowry, Dave; Scotti, Steve; Stewart, Jeff; Calomina, Anthony. National
 Aeronautics and Space Administration, DRAFT Materials, Structures, Mechanical Systems, and
 Manufacturing Roadmap, Technology Area 12, November 2010
- 1369 41. DOD and DOE Manufacturing Innovation Topics Workshop High Value Roll-to-Roll
 1370 Manufacturing Breakout Session, Fort Worth, TX, October 8, 2014
- 1371 42. Nanofabrication Technologies for Roll-to-Roll Processing: An Academic-Industry Workshop on
 1372 Technologies for American Manufacturing Competitiveness, Seaport Convention Center, Boston,
 1373 MA September 27, 2011
- 1374 43. Nanomanufacturing Summit 2013, University of Pennsylvania, Philadelphia, PA, October 15-17,
 1375 2013
- 1376 44. DOE, Bioenergy Technology Office, Workshop on Biomass Indirect Liquefaction (IDL), Golden,
 1377 CO, March 20-21, 2014.
- 1378 45. "Roll-to-roll flexible displays still far from reality", EE Times, February 10, 2006
- 1379 46. Randolph, Michael Aaron, "Commercial Assessment of Roll to Roll Manufacturing of Electronic
 1380 Displays', Masters Thesis, Massachusetts Institute of Technology, September 2006.
- 47. Subbaraman, Harish; Lin, Xiaohui; Xu, Xiaochuan, Dodabalapur, Ananth, Guo, L. Jay; Chen, Ray T.
 "Metrology and instrumentation challenges with high-rate, roll-to-roll manufacturing of flexible
 electronic systems.
- 48. Søndergaard, Roar; Hösel, Markus; Angmo, Dechan; Larsen-Olsen, Thue T.; Krebs, Frederik C.
 "Roll-to-roll fabrication of polymer solar cells". Materials Today, (15:1–2), January–February
 2012, Pages 36–49
- 1387 49. ORNL, Manufacturing Demonstration Facility (MDF), ORNL 2012-G01149
 1388 http://www.ornl.gov/user-facilities/mdf

DRAFT - PRE-DECISIONAL - DRAFT

- 1389 50. A National Strategic Plan for Advanced Manufacturing, Executive Office of the President, 1390 National Science and Technology Council, February 2012 1391 51. First Solar, Inc., Press Release, February 25, 2014 1392 52. Mridul Chada, Thin Film Solar Cell Efficiency Record Set By First Solar (Again), Clean Technica, August 7, 2014 1393 1394 53. Richard Karney, Emerging Technologies Building Technologies Office, "Windows R&D at the DOE 1395 Building Technologies Office", presented at the Building Enclosure Technology and Environment 1396 Council (BETEC) Symposium, Washington, DC, January 7, 2013 1397 54. 3M™Renewable Energy, Transmission & Conservation Technologies, Powering the Future 1398 Brochure, http://multimedia.3m.com/mws/media/4655750/3m-renewable-energy-1399 transmission-conservation-technologies.pdf. Accessed February 5, 2015 1400 1401
- 1402
- 1403
- 1404